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# Effect of morphology and impact of the electrode/electrolyte interface on the PEC response of Fe<sub>2</sub>O<sub>3</sub> based systems – comparison of two preparation techniques†

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The present study is a comparative account of Fe<sub>2</sub>O<sub>3</sub> based photoelectrodes prepared by two different techniques, namely spray pyrolysis and electrochemical deposition, followed by photoelectrochemical analysis at pH 13 (highly alkaline) and pH 8 (near neutral) in 0.1 M NaOH solution for solar hydrogen generation. The study also investigates the influence of morphology at the semiconductor electrode/electrolyte interface along with quantitative determination of the morphological parameters of the rough electrode surface affecting the photoelectrochemical response using power spectral density analysis. Studies revealed that the Fe<sub>2</sub>O<sub>3</sub> sample (E<sub>100cy</sub>) prepared with 100 cycles of electrochemical deposition showed the highest photocurrent density of 2.37 mA cm<sup>-2</sup> and 1.18 mA cm<sup>-2</sup> at 1 V vs. SCE at pH 13 and 8 respectively. Power spectral density analysis exhibited that E<sub>100cy</sub> possesses smallest surface features contributing to the PEC response with a lower cut off length scale of 17.23, upper cut off length scale of 150.45, maximum fractal dimension of 2.62 and maximum average rms roughness of 17.52 nm, offering the maximum surface area for charge transfer reactions at the electrode/electrolyte interface. The sample E<sub>100cy</sub> exhibited the highest ABPE of 1.29% and IPCE of 37.5%.

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## 1. Introduction

Solar driven water splitting also known as photoelectrochemical water splitting is one of the most promising techniques to produce hydrogen efficiently.<sup>1</sup> The demand of energy for the enormously growing population can be met by sustainable exploitation of renewable energy resources. From this perspective, hydrogen has attracted the attention of researchers worldwide due to its significantly high energy density of 120 MJ kg<sup>-1</sup>.<sup>2</sup> One of the major advantages of using this technique is that it produces hydrogen in the cleanest way possible and hence it is environmental friendly and an efficient approach.<sup>3,4</sup> Ever since the electrochemical photolysis experiment carried out on TiO<sub>2</sub> by Fujishima and Honda in 1972, researchers across the globe have been investigating PEC water splitting intensively.<sup>5</sup> In the past four decades, various semiconductor materials other than TiO<sub>2</sub> have been studied for their use as photoelectrode in PEC splitting of water.

Hematite ( $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>) is one of the most extensively used and promising semiconductor material which has gained significant attention as photoanode owing to its attractive properties *viz.* absorption in visible region which is approximately 40% of the solar spectrum, band gap of  $\sim$ 2.2 eV, stability in aqueous solutions, abundance and cost effectiveness.<sup>1,6</sup> The major challenge associated with hematite in PEC system is high rate of electron-hole pair recombination, poor diffusion length of minority charge carriers (2–4 nm), low depth of solar light penetration ( $\alpha^{-1} = 118$  nm at  $\lambda = 550$  nm) and slow kinetics of oxygen evolution reaction.<sup>7–10</sup> All these factors lead to reduced solar to chemical conversion efficiency and poor PEC performance of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>.

Many modifications have been adopted to tune the morphological, optical and electronic properties of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> in order to make it a suitable and ideal candidate for efficient solar water splitting. Enormous effort has been put in since 1972 in order to make PEC technology commercially viable by employing strategies like nano-structuring,<sup>7,11</sup> doping,<sup>1,12</sup> formations of heterojunction,<sup>13–16</sup> low energy and swift heavy ion irradiation,<sup>17,18</sup> deposition of catalyst<sup>19</sup> *etc.*

Fabrication of hematite thin films has been done in the past by variety of procedures *viz.* hydrothermal method,<sup>20–23</sup> chemical vapor deposition,<sup>7,8</sup> sputtering,<sup>24</sup> electrochemical deposition,<sup>9,25</sup> spray pyrolysis,<sup>13,26</sup> *etc.* and it was seen that the response of the material definitely depends on its method of preparation.

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Besides the method of preparation, reports are available that photoresponse does get affected due to particles of different shape and size, roughness, porosity and overall thickness of the deposition. In other words, the morphology of nanoparticles varies with the method of preparation which may in turn alter the optical and electronic properties and overall performance of PEC system.<sup>27,28</sup> Morphological related study on Fe<sub>2</sub>O<sub>3</sub> has been conducted by Sun *et al.* in which  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> films were fabricated using hydrothermal method with two different sets of precursors leading to formation of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> with different morphologies resulting in increased PEC response.<sup>29</sup> Electrochemical parameters like current,<sup>30–33</sup> impedance,<sup>27</sup> absorbance<sup>34</sup> and charge transients<sup>30,35</sup> have been studied in detail theoretically to establish correlation vis a vis morphology of the electrode.

Besides morphology there are other factors such as electrolyte, pH of electrolyte, annealing temperature *etc.* that have also been studied and are linked to be equally responsible for the photoelectrochemical performance and stability of photoelectrodes. Studies conducted on TiO<sub>2</sub>, ZnO, BiVO<sub>4</sub>, Fe<sub>2</sub>O<sub>3</sub>, *etc.* report significant alteration in the photocurrent due to variation in the pH of electrolyte.<sup>8,14,36–38</sup> Studies have also been conducted on the investigation of PEC performance of photoelectrodes in neutral or near neutral pH.<sup>8,14,19,39</sup> Comparative studies on Ti doped Fe<sub>2</sub>O<sub>3</sub> with Co–Ac catalyst have been performed at pH 8 and 12.5 by Banerjee *et al.*<sup>19</sup> However, poor photoelectrochemical performance and stability in neutral pH electrolyte in case of low band gap materials such as Fe<sub>2</sub>O<sub>3</sub> based systems is a major concern. In order to make PEC technique a commercially viable and common practice for solar hydrogen generation we require photoelectrode systems which are ubiquitous in nature, cost effective to synthesize, have low band gap so that they can absorb maximum portion of solar spectrum, eco-friendly and most importantly, can work under neutral to near neutral pH electrolyte.

The present communication attempts fabrication of pristine hematite films by economic and facile methods of spray pyrolysis and electrochemical deposition for their application in highly alkaline to near neutral pH electrolyte. Photoelectrochemical performances of electrodes prepared by both the techniques were studied separately in 0.1 M NaOH solution at highly alkaline pH 13. The optimized electrodes with the best PEC response were chosen for further comparative studies at a near neutral pH 8 in 0.1 M NaOH solution and were characterized using X-ray diffraction spectroscopy (XRD), Atomic force microscopy (AFM), Field-emission scanning electron microscopy (FE-SEM), Power Spectral Density (PSD) analysis *etc.* Power Spectral Density (PSD) analysis which is an important and powerful tool has been used for quantitative examination of the morphology of rough surface topography of hematite electrodes apparently for the first time. A power spectrum (PS) of the rough surface obtained from PSD analysis provides quantitative measure of various surface roughness parameters like lower (*l*) cut-off length scale, upper (*L*) cut-off length scale and fractal dimension (*D<sub>H</sub>*). The surface profile of a rough electrode is converted into its corresponding spatial wavelengths over the sampling area.<sup>33</sup> The smallest surface feature taking part in electrochemical reaction is the lower (*l*) cut-off length scale

while the largest surface feature is the upper (*L*) cut-off length scale. The fractal dimension (*D<sub>H</sub>*) describes the roughness scale and is indicative of the distribution of fractal surfaces in space.<sup>40,41</sup> Morphological parameters obtained for electrodeposited and spray deposited hematite electrodes were interpreted and correlated with electrochemical and photoelectrochemical results to draw a characteristic relationship between the morphology and PEC performance of hematite electrodes.

## 2. Experimental

### 2.1. Sample preparation

**2.1.1. Preparation of Fe<sub>2</sub>O<sub>3</sub> nanostructured thin films by electrodeposition method.** Thin films of Fe<sub>2</sub>O<sub>3</sub> were deposited on transparent conductive fluorine-doped tin oxide (FTO) substrate by electrochemical deposition. Standard three electrode electrochemical cell with platinum as the counter electrode, saturated calomel electrode as the reference electrode and FTO (1.2 cm × 1.5 cm) as the working electrode was used for this purpose. The electrodeposition bath mixture was prepared by mixing aqueous solution of 5 mM FeCl<sub>3</sub> (iron(III) chloride), 5 mM NaF (sodium fluoride), 0.10 M KCl (potassium chloride) and 1 M H<sub>2</sub>O<sub>2</sub> (hydrogen peroxide).<sup>1,42,43</sup> The process of electrochemical deposition was performed using cyclic voltammetry in the potential range of –0.5 V to 0 V at a sweep rate of 0.1 V s<sup>–1</sup>. The temperature was maintained at 50 °C during the entire process of deposition.<sup>44,45</sup> Number of cycles of Fe<sub>2</sub>O<sub>3</sub> deposition was varied to prepare films of varying thickness. In this manner, three different sets of samples were fabricated with number of cycles of deposition of Fe<sub>2</sub>O<sub>3</sub> being kept at 50, 100 and 150. The prepared Fe<sub>2</sub>O<sub>3</sub> thin film samples were rinsed with distilled water and sintered at 500 °C for 3 hours in a tubular furnace.

**2.1.2. Preparation of Fe<sub>2</sub>O<sub>3</sub> nanostructured thin films by spray pyrolysis technique.** Nanostructured thin films of Fe<sub>2</sub>O<sub>3</sub> were fabricated by spraying precursor solution containing 0.15 M Iron(III) nitrate nonahydrate (Fe(NO<sub>3</sub>)<sub>3</sub>·9H<sub>2</sub>O) on ITO (1.2 cm × 1.5 cm) glass substrate. The temperature of the system was maintained at 350 °C during the whole process of deposition.<sup>26</sup> Prior to the deposition, 0.5 cm from the length of the substrate was covered with aluminium foil for making ohmic contact. The duration of spray was varied as 20 s, 30 s, 40 s and 50 s to prepare four different sets of samples with varying thickness.

**2.1.3. Preparation of photoelectrodes.** All the samples prepared by electrodeposition and spray pyrolysis were converted into electrodes by making an ohmic contact with the help of copper wire, silver paste and epoxy (Hysol, Singapore) on the portion of ITO and FTO films, which was left undeposited for the same purpose. These electrodes were then used for photoelectrochemical analysis. The description of the prepared samples and their acronym used is summarized in Table 1.

### 2.2. Characterizations

The X-ray diffraction (XRD) patterns of spray pyrolytically and electrodeposited thin films of Fe<sub>2</sub>O<sub>3</sub> were recorded with X-ray diffractometer (Bruker AXS, D8 Advance) using Cu K $\alpha$



Table 1 Description of Fe<sub>2</sub>O<sub>3</sub> thin films prepared

Sr. no.	Description of prepared thin films	Sample acronym	Average film thickness	Average crystallite size (nm)
1	Fe <sub>2</sub> O <sub>3</sub> film electrodeposited with 50 cycles	E_50cy	550 nm	75
2	Fe <sub>2</sub> O <sub>3</sub> film electrodeposited with 100 cycles	E_100cy	1 μm	80
3	Fe <sub>2</sub> O <sub>3</sub> film electrodeposited with 150 cycles	E_150cy	1.5 μm	90
4	Spray pyrolytically deposited Fe <sub>2</sub> O <sub>3</sub> film for 20 s	S_20s	250 nm	25
5	Spray pyrolytically deposited Fe <sub>2</sub> O <sub>3</sub> film for 30 s	S_30s	380 nm	33
6	Spray pyrolytically deposited Fe <sub>2</sub> O <sub>3</sub> film for 40 s	S_40s	520 nm	45
7	Spray pyrolytically deposited Fe <sub>2</sub> O <sub>3</sub> film for 50 s	S_50s	600 nm	40

radiation ( $\lambda = 1.5418 \text{ \AA}$ ). The glancing angle ( $2\theta$ ) was varied from  $20^\circ$  to  $60^\circ$  to record the XRD pattern. Debye–Scherrer equation was employed to determine the crystallite phase and crystallite size. Information about the morphology and topography of thin films prepared by both the methods were obtained by Field-Emission Scanning Electron Microscopy (FE-SEM, Tescan Mira II LMH) and Atomic Force Microscopy (AFM, Nanoscope IIIa Scanning Microscope Controller, Digital Instruments) respectively. Optical absorption spectra for all the Fe<sub>2</sub>O<sub>3</sub> samples were measured with the help of UV-visible spectrophotometer (Shimadzu, UV-2450). The obtained absorption spectrums were further studied to determine band gap of all the samples. Thickness of all the prepared Fe<sub>2</sub>O<sub>3</sub> thin films was determined by means of surface profilometer (Bruker DektakXT).

### 2.3. Power spectral density analysis

Power spectrum which reveals information about all the roughness parameters was obtained from AFM images of spray pyrolytically and electrodeposited Fe<sub>2</sub>O<sub>3</sub> samples. To serve this purpose, AFM images of Fe<sub>2</sub>O<sub>3</sub> thin films prepared using spray pyrolysis and electrodeposition methods were recorded at varying resolutions. These AFM images were analyzed by Nanoscope analysis software associated with the scanning probe instrument to obtain the power spectrum. The power spectrum so obtained was further interpreted to calculate the morphological parameters such as lower cut off length scale ( $l$ ), upper cut off length scale ( $L$ ) and the fractal dimension ( $D_H$ ).

### 2.4. Electrochemical and photoelectrochemical studies

All the prepared Fe<sub>2</sub>O<sub>3</sub> thin films were subjected to electrochemical and photoelectrochemical measurements inside a three electrode assembly cell filled with 0.1 M NaOH (at pH 13 and 8) electrolyte kept in a quartz compartment at room temperature. 0.1 M NaOH solution of pH 8 was prepared by neutralizing 0.1 M NaOH solution of pH 13 with 1 M H<sub>3</sub>PO<sub>4</sub> which reduces the pH without affecting the molarity. Thin films of Fe<sub>2</sub>O<sub>3</sub> were employed as the working electrode, platinum mesh as the counter electrode and saturated calomel electrode (SCE) as the reference electrode. The whole system was connected to an electrochemical work station (Zahner Zehnnium-PP211, Germany). Fe<sub>2</sub>O<sub>3</sub> electrodes with an area of 1 cm<sup>2</sup> were exposed to solar radiations using a 150 W xenon arc lamp (Newport, RI, USA) with intensity of 1 sun illumination (100 mW cm<sup>-2</sup>). Photocurrent density analysis was conducted with an applied bias being varied from  $-1.0 \text{ V}$  to  $1.0 \text{ V}$  vs. SCE at the

scan rate of  $10 \text{ mV s}^{-1}$ . Transient open circuit potential studies were conducted for all the electrodes at regular interval of 20 s for duration of 120 seconds. Mott–Schottky measurements were also carried out to measure the capacitance ( $C$ ) of the electrical double layer for all the Fe<sub>2</sub>O<sub>3</sub> electrodes in dark condition. The applied bias was varied from  $-1 \text{ V}$  to  $1 \text{ V}$  at 5 mV amplitude with an operating AC signal frequency of 1 kHz. The Mott–Schottky curve follows the following equation:<sup>46</sup>

$$\frac{1}{C^2} = \left( \frac{2}{q\epsilon_0\epsilon N_D} \right) \left( V_{\text{app}} - V_{\text{FB}} - \frac{kT}{q} \right) \quad (1)$$

where,  $q$  stands for the electronic charge,  $\epsilon_0$  for permittivity of the vacuum,  $\epsilon$  is the dielectric constant of the semiconductor Fe<sub>2</sub>O<sub>3</sub>,  $N_D$  represents the donor density,  $V_{\text{FB}}$  represents the flat band potential, and  $kT/q$  is the temperature dependent term. The intercept of Mott–Schottky curve provides the magnitude of flat band potential.

Electrochemical impedance spectroscopy (EIS) is an important technique to study the charge transfer kinetics at the semiconductor electrode/electrolyte interface. For this, a sinusoidal AC frequency at 5 mV amplitude was varied from 100 mHz to 10 kHz in sweep mode. Nyquist and Bode plot were obtained under dark and illumination for all the samples.

### 2.5. Efficiency measurements

Applied bias photon-to-current efficiency (ABPE) is calculated by using the following equation:<sup>13</sup>

$$\text{ABPE} = \left[ \frac{J_{\text{ph}} (\text{mA cm}^{-2}) \times (1.23 - |V_b|) (\text{V})}{P_{\text{total}} (\text{mW cm}^{-2})} \right] \quad (2)$$

where,  $J_{\text{ph}}$  is the obtained photocurrent density of the working electrode,  $V_b$  is the external voltage applied and  $P_{\text{total}}$  is the illumination power intensity of the light source used.

Incident photon-to-current efficiency (IPCE) was recorded using Zahner, PP211 (CIMPS-pcs, Germany) electrochemical workstation within a three electrode cell. The measurements were carried out in the illumination range of 350–800 nm.

Chronoamperometric measurements were performed to check for the stability of the prepared electrodes under illumination for duration of 1 hour in near neutral pH *i.e.* 8.

## 3. Results and discussion

### 3.1. Crystallite size and phase analysis

The X-ray diffraction patterns of the thin film samples of Fe<sub>2</sub>O<sub>3</sub> prepared by spray pyrolysis and electrodeposition are shown in



Fig. 1(A and B) respectively. The prominent peaks in Fig. 1(A) at  $24.16^\circ$ ,  $33.18^\circ$ ,  $35.65^\circ$ ,  $40.88^\circ$ ,  $49.49^\circ$ ,  $54.10^\circ$  belong to respective (012), (104), (110), (113), (024) and (116) planes for rhombohedral system of hematite phase of  $\text{Fe}_2\text{O}_3$  and are confirmed by the JCPDS card no. 01-073-2234. The remaining peaks correspond to the underlying substrate ITO. In Fig. 1(B), the peaks at glancing angle ( $2\theta$ ) of  $24.16^\circ$ ,  $33.19^\circ$ ,  $35.65^\circ$ ,  $40.89^\circ$ ,  $49.50^\circ$  and  $54.12^\circ$  correspond to (012), (104), (110), (113), (024) and (116) planes respectively and corresponds to the JCPDS card no. 01-085-0599. All these peaks confirm the hematite phase with rhombohedral system of  $\text{Fe}_2\text{O}_3$ . The other peaks in the XRD pattern are of the FTO substrate. The average crystallite size of all the samples were calculated using Debye–Scherrer equation and are reported in Table 1.<sup>47</sup>

### 3.2. Photoelectrochemical analysis

Steady state photocurrent density plots as a function of applied potential ( $V$  vs. SCE) for all the samples are shown in Fig. 2. Studies conducted at pH 13 *i.e.* under high alkaline conditions, reveals that all the  $\text{Fe}_2\text{O}_3$  electrodes synthesized by spray pyrolysis technique exhibit lower photocurrent as compared to the  $\text{Fe}_2\text{O}_3$  electrodes prepared by electrochemical deposition. In case of the electrodes prepared by spray pyrolysis, the sample with spray deposition time of 40 s *i.e.* sample S\_40s exhibits the maximum photocurrent density of  $0.43 \text{ mA cm}^{-2}$  at 1 V vs. SCE (Fig. 2(A)) while under similar pH conditions, the electrodeposited  $\text{Fe}_2\text{O}_3$  sample with 100 cycles of deposition exhibited photocurrent density of  $2.37 \text{ mA cm}^{-2}$  at 1 V vs. SCE with a decrease in the onset potential by  $\sim 200 \text{ mV}$  (Fig. 2(B)). The photocurrent density values for E\_100cy showed approximately 5.5 fold enhancement as compared to S\_40s. Photoelectrochemical response of hematite largely depends on the quantity of the photoactive material deposited on the substrate which is directly related to the thickness of the film. For this reason, the photocurrent density increases with the increase in the spray time of deposition in case of spray deposition and increase in the number of cycles for electrochemical deposition. After reaching an optimal

concentration of  $\text{Fe}_2\text{O}_3$  material, a decrease in the photocurrent density values is observed in both the case of deposition of  $\text{Fe}_2\text{O}_3$ .<sup>19,48</sup> Hence, photocurrent density values decrease for S\_50s and E\_150cy. The excess deposition on the substrate reduces the diffusion length of holes by hampering their transfer to the semiconductor/electrolyte interface.<sup>19,49</sup>

From this study, spray and electrochemically deposited  $\text{Fe}_2\text{O}_3$  samples exhibiting the highest photoresponse at pH 13 *i.e.* samples E\_100cy and S\_40s were chosen to be studied for further analysis at pH 8. The comparative photocurrent density analysis (Fig. 2(C)) for the samples E\_100cy and S\_40s at pH 8 reveals that photocurrent density values decreased significantly at pH 8. However, the electrodeposited  $\text{Fe}_2\text{O}_3$  electrode remains the best sample out of the two and shows highest photocurrent density of  $1.18 \text{ mA cm}^{-2}$  at 1 V vs. SCE with  $\sim 8$  fold increment in comparison to the spray deposited sample with photocurrent density of  $0.15 \text{ mA cm}^{-2}$  at 1 V vs. SCE. Comparison of photoelectrochemical performances of the samples S\_40s and E\_100cy at the studied pH *i.e.* 13 and 8 shows that the photocurrent density values of S\_40s sample decreased considerably by  $\sim 3$  fold while for E\_100cy it reduced by  $\sim 2$  fold.<sup>8</sup> The onset potential for the sample S\_40s increased from 0.40 V (at pH 13) to 0.52 V (at pH 8) with a shift of 220 mV whereas, in case of E\_100cy, the onset potential remained at 0.20 V. Lower values of onset potential mark faster transfer of holes towards the semiconductor/electrolyte interface which in turn hinder electron hole pair recombination in the bulk of semiconductor.<sup>49</sup>

### 3.3. Surface morphology analysis

$\text{Fe}_2\text{O}_3$  samples exhibiting the highest photoresponse *i.e.* S\_40s and E\_100cy were examined by Field-emission scanning electron microscopy for the analysis of morphological factors contributing to higher photoelectrochemical response. Scanning electron micrographs of S\_40s and E\_100cy samples are shown in Fig. 3. The SEM image of spray pyrolytically deposited sample S\_40s (Fig. 3(A)) shows compact and uniform packing of the spindle shaped or rhombohedral grains. The morphology of

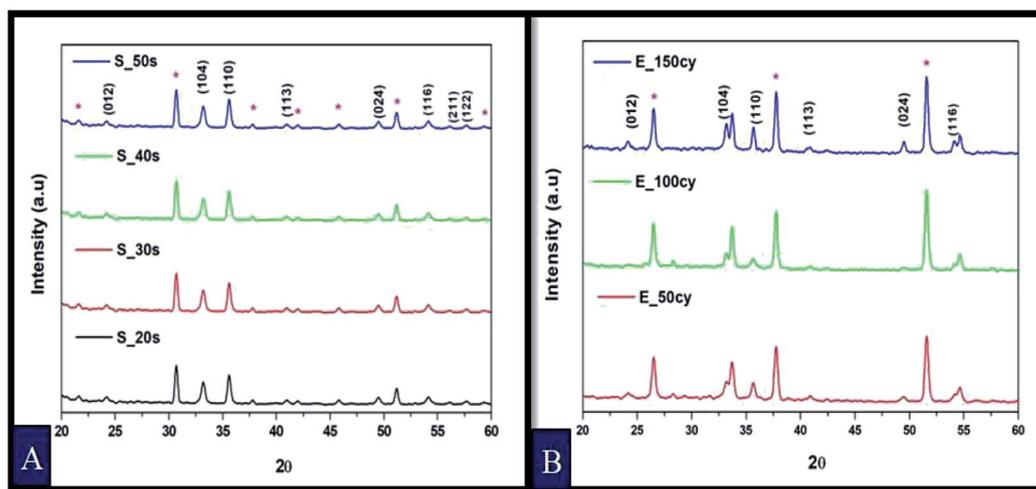


Fig. 1 XRD patterns of  $\text{Fe}_2\text{O}_3$  thin films prepared by (A) spray pyrolysis and (B) electrodeposition.



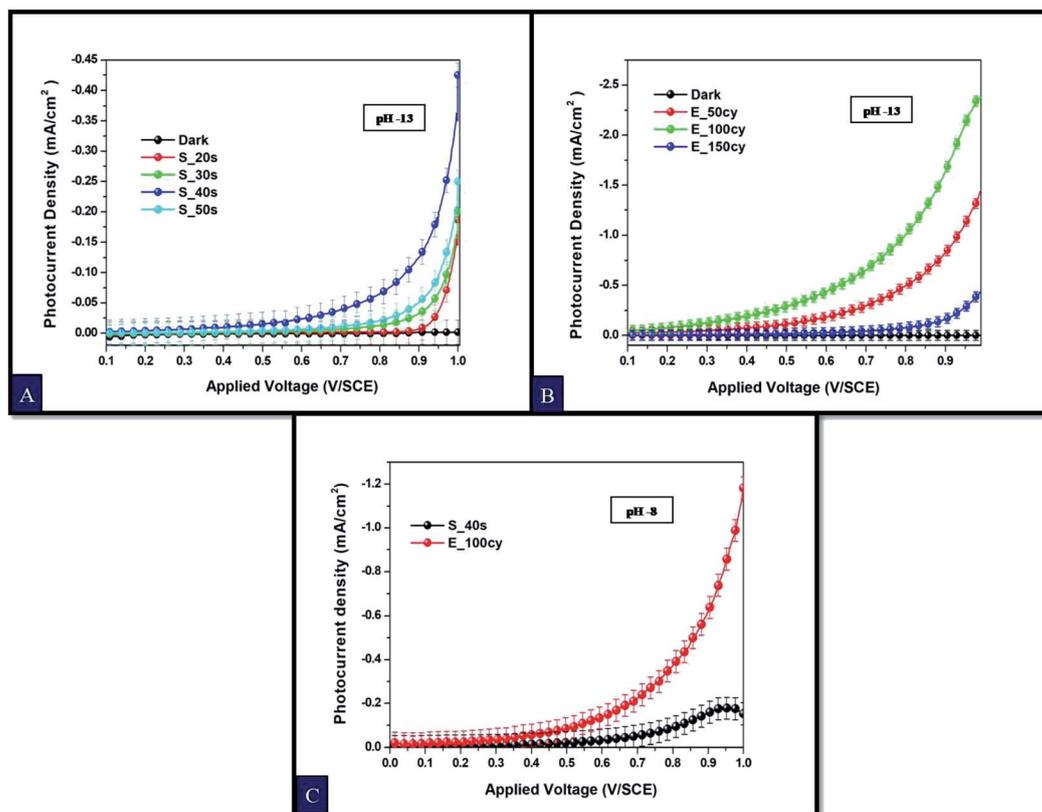


Fig. 2 Photocurrent density curves of  $\text{Fe}_2\text{O}_3$  electrodes at pH 13 in 0.1 M NaOH solution prepared by (A) spray pyrolysis, (B) electrodeposition and (C) comparative photocurrent density curves at pH 8.

particles reveals mesoporous deposition throughout the film surface. The grain size varies from 30–60 nm and is in agreement with the crystallite size measured from XRD analysis.<sup>50</sup> FE-SEM images of all the spray deposited samples are provided in Fig. S1.† It is clear from the Fig. S1† that the number of grains and the porosity increases with the increase in deposition time from 20 s to 40 s. The thin film sample S\_40s seems to be the

sample with clearly defined grains and least agglomeration. The sample has highly mesoporous network of grains. As the deposition time is further increased to 50 s, grain size decreases and agglomeration of grains is seen. The thickness of film increases with the increase in the deposition time. Thinner films like S\_20s and S\_30s do not possess sufficient number of grains to absorb maximum portion of solar spectrum.<sup>24</sup> Fig. 3(B)

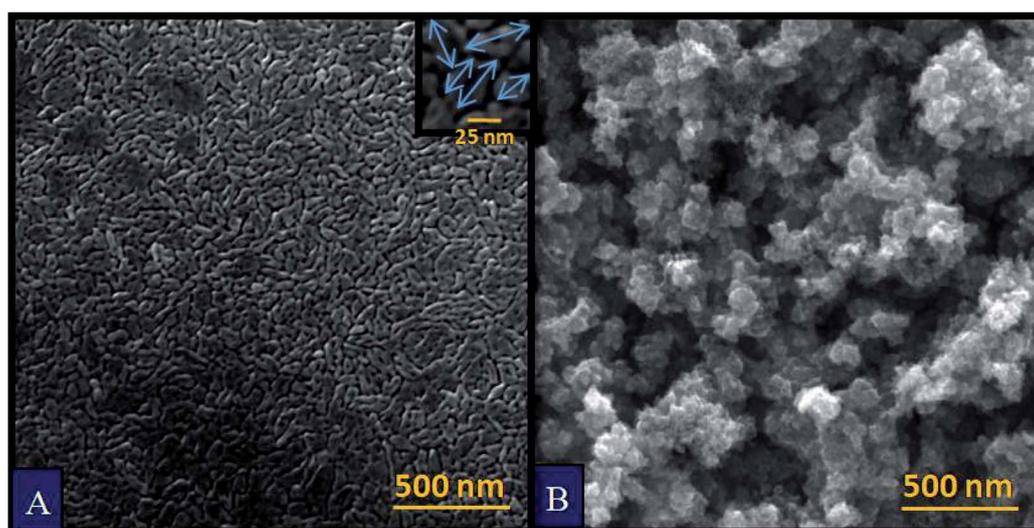


Fig. 3 FE-SEM images of  $\text{Fe}_2\text{O}_3$  thin films prepared by (A) spray pyrolysis and (B) electrodeposition.



shows FE-SEM image of E\_100cy  $\text{Fe}_2\text{O}_3$  sample. The micrograph reveals highly porous network of particles consisting of hollow microspheres. The particles on the top appear highly rough which indicates that they consist of many loosely packed nanoparticles. Fig. S2† shows FE-SEM images of all the electrodeposited  $\text{Fe}_2\text{O}_3$  samples. It can be seen that the number of particles and porosity of the film increases with the increase in the number of cycles of deposition.<sup>25</sup> An optimum film thickness present in the sample S\_40s (~520 nm) and E\_100cy (~1  $\mu\text{m}$ ) allows maximum absorption of solar radiations and also prevents bulk recombination of charge carriers.<sup>19,51</sup> As the film thickness increases further in case of S\_50s (~600 nm) and E\_150cy (~1.5  $\mu\text{m}$ ), charge carrier recombination becomes more prominent. In addition to this, increasing number of particles and grain boundaries lead to shorter diffusion length of holes to the semiconductor/electrolyte interface which in turn cause reduced PEC response.<sup>24</sup>

It is evident from the Fig. 3 that the morphology of particles deposited by spray and electrodeposition methods is totally different. The morphology of S\_40s is compact with flat spindle and rhombohedral grains while particles in E\_100cy are loosely arranged with highly porous framework. Higher photoresponse in E\_100cy could be attributed to the thickness of film, high degree of porosity and rough nanoparticles.

### 3.4. Topographical analysis

Three dimensional atomic force micrographs of  $\text{Fe}_2\text{O}_3$  samples S\_40s and E\_100cy are provided in the Fig. 4 for the analysis of surface topography. It is clearly observed from the micrographs that electrodeposited sample E\_100cy possesses more surface roughness as compared to the spray pyrolytically deposited sample S\_40s. Values of rms roughness for all the samples prepared are provided in Table 2. This increased roughness facilitates separation and transfer of electron and holes and thus prevents their recombination in the bulk of the semiconductor.

### 3.5. Power spectral density (PSD) analysis

Power Spectral Density (PSD) measurements of all the prepared nanostructured  $\text{Fe}_2\text{O}_3$  thin films were performed using AFM

instrumentation. Power Spectral Density (PSD) analysis provides quantitative measurements of surface roughness parameters in the form of a curve of the amplitude of surface roughness with respect to spatial wavelengths. It thus helps in interpreting the surface features of a rough electrode and provides three dimensional information about the distribution of surface features. In PSD, A power-law spectrum is used to describe any rough surface. This spectrum consists of a wavenumbers scale as x-axis with a high and a low wavenumber cut-off. The intermediate region or the curved region in the power spectrum is the region between two flat regions of low and high wavenumber.<sup>52</sup>

AFM images recorded at various resolutions were investigated by PSD analysis to obtain average values of surface roughness parameters such as lower cut off length scale ( $l$ ), upper cut off length scale ( $L$ ) and fractal dimension ( $D_H$ ). The method for calculation of surface roughness parameters has been explained elsewhere.<sup>41</sup> The point considered for calculation of lower cut off length scale and upper cut off length scale are indicated in Fig. 5 by smaller arrows at high wavenumber region and longer arrows at low wavenumber region of power spectrum respectively. It can be observed that the lower and higher cut off length values of the sample prepared by electrochemical deposition E\_100cy are at the lower wavenumbers in comparison to the sample prepared by spray pyrolysis S\_40s. The corresponding values of all the roughness parameters for S\_40s and E\_100cy are reported in Table 2. However, the fractal dimension calculated from the slope of the curve which represents the distribution of fractal surfaces in space is higher for E\_100cy.

Table 2 Morphological parameters obtained from power spectrum

Sample description	Average PSD parameters			Rms roughness (nm)
	$D_H$	$l$ (nm)	$L$ (nm)	
S_40s	2.30	12.11	120.02	12.45
E_100 cy	2.62	17.23	150.45	17.52

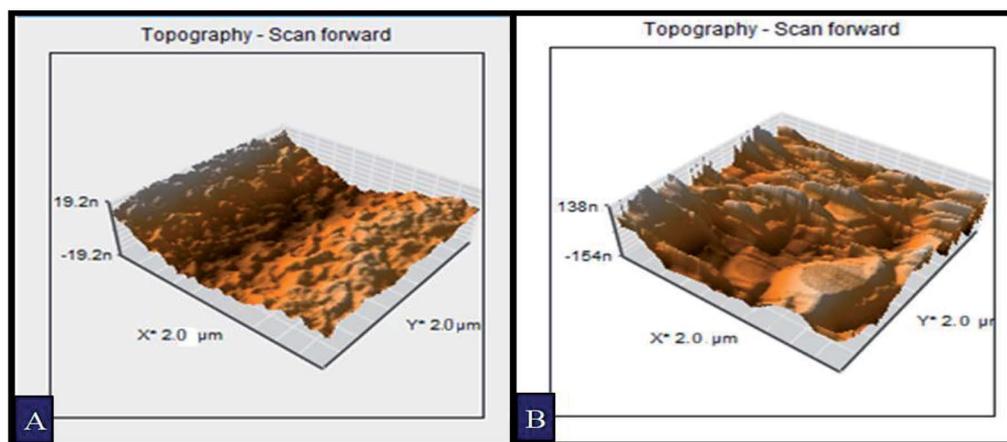


Fig. 4 AFM images of  $\text{Fe}_2\text{O}_3$  thin films prepared by (A) spray pyrolysis and (B) electrodeposition.



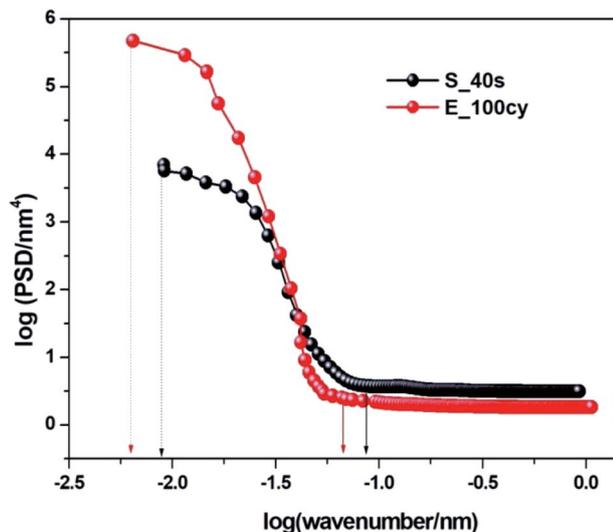


Fig. 5 Power spectrum of  $\text{Fe}_2\text{O}_3$  thin films prepared by spray pyrolysis and electrodeposition.

An increase in the  $D_H$  is indicative of amplification in the number of clefts or folds on the surface of electrode which makes the film uneven and rougher. This clearly indicates that the sample E\_100cy has highly distributed three dimensional arrangements of rough surface features as compared to the sample S\_40s.

### 3.6. EIS and PEIS measurements

Electrochemical impedance analysis was conducted to obtain Nyquist and Bode plot (Fig. 6). An in-depth understanding of the charge transfer kinetics at the electrode/electrolyte interface can be acquired by this powerful technique. Fig. 6(A and B) shows Nyquist plots obtained for dark and illumination studies of  $\text{Fe}_2\text{O}_3$  samples. Inset in Fig. 6(B) represents the equivalent Randles circuit for the systems studied. Randles circuit parameters for fitting EIS data are shown in Table S1.† The sample E\_100cy possesses the smallest semicircular curve in Fig. 6(A) which turns into shorter semicircles when exposed to solar radiations. This shortening of the semicircular curve indicates decline in the charge transfer resistance of the system.<sup>19</sup> It is clear that sample prepared by electrochemical deposition possesses the least charge transfer resistance under both dark and illumination conditions.

Bode absolute impedance plot and Bode phase plot are shown in Fig. 6(C and D). Bode absolute impedance plot ( $Z$ ) is a curve obtained from absolute values of impedance with respect to applied frequency while Bode phase plot is a plot of phase angle against frequency. The study was conducted in dark. It is observed that the magnitude of impedance decreased remarkably for E\_100cy. It is reported that morphological factors of a surface, viz., roughness, porosity and fractal dimension greatly influence the impedance of an electrode.<sup>27</sup> The phase plot shows lower value of phase angle for the sample E\_100cy which represents increased

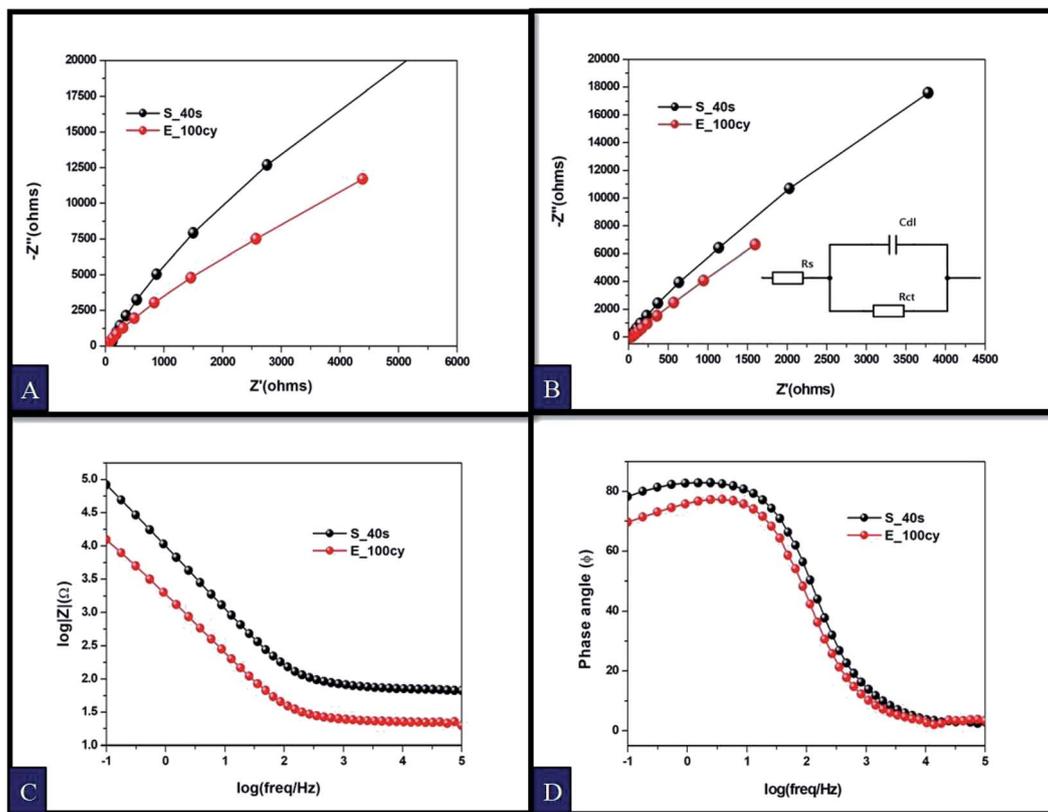


Fig. 6 (A) Nyquist plot under dark, (B) Nyquist plot under illumination, (C) Bode absolute impedance plot and (D) Bode phase plot of  $\text{Fe}_2\text{O}_3$  thin films prepared by spray pyrolysis and electrodeposition.



Table 3 Electrochemical parameters of the spray pyrolytically and electrodeposited samples

Sample description	Flat band potential $V_{FB}$ (V vs. SCE)	Donor density $N_D$ ( $\text{cm}^{-3}$ )	Band gap (eV)	PCD at 1 V vs. SCE				Onset potential $V_{OC}$ (V vs. SCE)	
				At pH 8	At pH 13	% ABPE	% IPCE	At pH 8	At pH 13
S_40s	-0.20	$9.60 \times 10^{17}$	2.1	0.15	0.43	1.10	21.2	0.52	0.40
E_100 cy	-0.37	$7.84 \times 10^{20}$	2.0	1.18	2.37	1.29	37.5	0.20	0.20

heterogeneity of the electrode surface. All these results obtained are in agreement with the morphological parameters calculated from power spectrum. Sample E\_100cy on account of having highest fractal dimension, least charge transfer resistance and impedance contributed more to photoelectrochemical response.

### 3.7. Optical absorption analysis

The optical absorbance spectra of thin film samples recorded using UV-vis spectrophotometer in 300–800 nm range is shown in Fig. S3(A).† An intense absorption edge is observed at 600 nm.  $\text{Fe}^{3+}$  3d to 3d spin forbidden transition excitation is the reason for the absorption in the visible region.<sup>26</sup> The sample prepared by

electrodeposition (E\_100cy) exhibits maximum absorption intensity as compared to the sample prepared by spray pyrolysis (S\_40s) corresponding to the band gap of 2.0 eV as shown in Fig. S3(B).† The band gap of the sample S\_40s is calculated to be 2.1 eV. The increased absorption in E\_100cy could be attributed to increased thickness of film in case of the sample E\_100cy ( $\sim 1 \mu\text{m}$ ) which is significantly less in the sample S\_40s ( $\sim 520 \text{ nm}$ ).<sup>51</sup>

### 3.8. Mott–Schottky analysis

Mott–Schottky was performed for both the spray and electrodeposited samples to acquire understanding about the kinetics of charge transfer at the semiconductor/electrolyte interface.

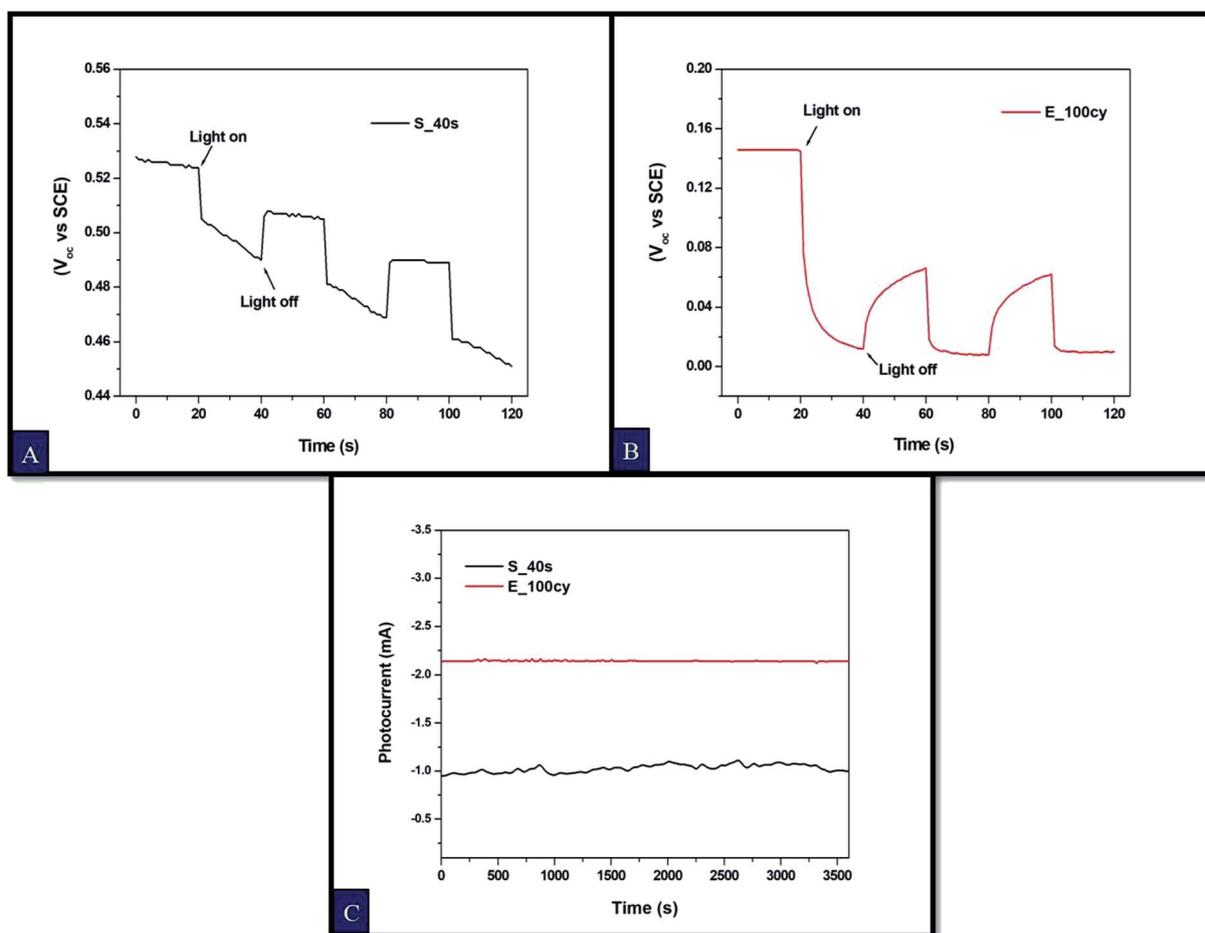


Fig. 7 Transient open circuit potential curves for Fe<sub>2</sub>O<sub>3</sub> thin films prepared by (A) spray pyrolysis, (B) electrodeposition and (C) chronoamperometry curves at pH 8 under constant illumination.



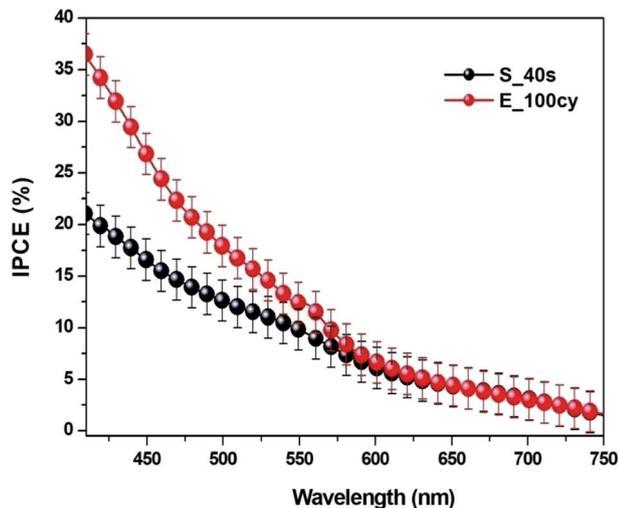


Fig. 8 IPCE of  $\text{Fe}_2\text{O}_3$  thin films prepared by spray pyrolysis and electrodeposition.

The Mott–Schottky curve for both the samples S\_40s and E\_100cy is shown in Fig. S4.† The positive slope of the curve is obtained in both the samples which signify the n-type conductivity of  $\text{Fe}_2\text{O}_3$  films. Flat band potential values were calculated from the intercept of curve at zero applied bias. It could be observed that the value of flat band potential for the sample S\_40s is  $-0.20$  V vs. SCE and for E\_100cy it is  $-0.37$  V vs. SCE. The more negative flat band potential value for the sample E\_100cy indicates increased band bending which hampers the recombination of charge carriers in the bulk of semiconductor. This in turn promotes the separation of charge carriers at the semiconductor/electrolyte interface and thus aids in augmenting the PEC response.<sup>53</sup> Donor density ( $N_D$ ) was calculated and is reported in Table 3 which is maximum in case of sample E\_100cy. Higher donor density reduces the resistivity in the film and improves PEC response.

### 3.9. Charge carrier recombination analysis and chronoamperometry studies

Charge carrier recombination kinetics was investigated from open circuit potential decay plots. For this purpose, transient open circuit potential curves were obtained for the sample S\_40s and E\_100cy with continuous light on and off cycles at the interval of 20 s as shown in Fig. 7A and B. This scan was conducted for two minutes. A cathodic shift in the open circuit potential was observed for both the samples which is in well agreement with the Mott–Schottky studies. This cathodic shift could be attributed to shift in the Fermi energy level.<sup>19</sup> The open circuit potential value is higher for the sample E\_100cy as compared to S\_40s which indicated more charge recombination in case of S\_40s.

Chronoamperometry measurements were also conducted to study the stability of the  $\text{Fe}_2\text{O}_3$  samples S\_40s and E\_100cy under constant illumination at pH 8. The chronoamperometry curve is provided in Fig. 7(C), from which it is evident that the sample E\_100cy exhibits higher photocurrent without much

fluctuation for continuous duration of 1 hour. On the contrary, the curve for the sample S\_40s seems noisy and gives lesser photocurrent under same conditions of electrolyte for 1 hour. Hence, the sample E\_100cy is more stable as compared to S\_40s.

### 3.10. Efficiency measurements

Applied bias photon-to-current efficiency (ABPE) was calculated for all the  $\text{Fe}_2\text{O}_3$  samples using eqn (2). The sample E\_100cy possesses the maximum efficiency of 1.29% while ABPE for S\_40s is 1.10% at pH 8.

The IPCE of all the samples as a function of wavelength is shown in Fig. 8. It is of greater significance as it represents generation of photocurrent as a result of absorption of photons by the semiconductor. It is clear that the absorption of photons by both the samples *i.e.* S\_40s and E\_100cy occurs in the visible region of solar spectrum. This is in well agreement with the data obtained from optical absorbance studies. A higher value of IPCE was obtained for the sample E\_100cy which is 37.5% while S\_40s exhibits IPCE of 21.2% at 1 V vs. SCE.

## 4. Conclusions

Comparative study on the performance of  $\alpha\text{-Fe}_2\text{O}_3$  electrodes prepared by two different techniques *viz.* electrochemical deposition and spray pyrolysis in PEC system has been undertaken.  $\alpha\text{-Fe}_2\text{O}_3$  thin film samples prepared by both the techniques exhibiting the best response in 0.1 M NaOH solution at pH 13 were further studied at near neutral pH 8. Studies at pH 13 revealed that the  $\text{Fe}_2\text{O}_3$  sample prepared by spray pyrolysis with 40 s deposition time (S\_40s) and electrodeposited sample with 100 cycles of deposition (E\_100cy) showed highest photocurrent density (PCD) of  $0.43$  mA  $\text{cm}^{-2}$  and  $2.37$  mA  $\text{cm}^{-2}$  respectively at 1 V vs. SCE. Further studies at pH 8 with the two best samples S\_40s and E\_100cy demonstrated that the sample E\_100cy exhibited maximum PEC response with PCD of  $1.18$  mA  $\text{cm}^{-2}$  in comparison to S\_40s ( $0.15$  mA  $\text{cm}^{-2}$ ) at 1 V vs. SCE. Moreover, morphological parameters obtained from power spectral density analysis showed that E\_100cy offered maximum surface area for charge transfer reactions at electrode/electrolyte interface owing to maximum fractal dimension of 2.62 and maximum average rms roughness of 17.52 nm. The sample E\_100cy also exhibited highest ABPE of 1.29% and IPCE of 37.5%.

## Conflicts of interest

There are no conflicts to declare.

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